

(FILE 'HOME' ENTERED AT 13:04:40 ON 04 NOV 2004)

FILE 'INSPEC, CAPLUS' ENTERED AT 13:04:47 ON 04 NOV 2004

L1 23589 S SIGE OR SILICON GERMANIUM  
L2 83053 S RECRYSTALLIZATION OR RE-CRYSTALLIZATION  
L3 77 S L1 AND L2  
L4 0 S L3 AND (NICKEL OR NI)  
L5 14 S L3 AND STRAINED

FILE 'STNGUIDE' ENTERED AT 13:06:27 ON 04 NOV 2004

FILE 'INSPEC, CAPLUS' ENTERED AT 13:09:57 ON 04 NOV 2004

L6 35905 S SILICON OXIDE  
L7 34924 S SILICON DIOXIDE  
L8 68436 S L6 OR L7  
L9 2485619 S (OXYGEN OR O) OR (HELIUM OR HE)  
L10 22697 S L9 (S) (DOPING OR IMPLANTATION)  
L11 22697 S L9 AND L10  
L12 725 S L8 AND L11  
L13 3346 S SMALL CRYSTALS  
L14 0 S L12 AND L13  
L15 71884 S VOIDS OR VOID  
L16 4 S L15 AND L12

FILE 'STNGUIDE' ENTERED AT 13:12:05 ON 04 NOV 2004

FILE 'INSPEC, CAPLUS' ENTERED AT 13:14:13 ON 04 NOV 2004

L17 77 S ITOX  
L18 47 S L9 AND L17  
L19 5 S L18 AND L1

FILE 'STNGUIDE' ENTERED AT 13:14:55 ON 04 NOV 2004

FILE 'INSPEC, CAPLUS' ENTERED AT 13:16:25 ON 04 NOV 2004

L20 4090 S INTERNAL OXIDATION  
L21 1683 S L20 AND L9  
L22 3 S L20 AND L1